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# Structure and properties of intrinsic and extrinsic defects in black phosphorus†

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The electronic and geometric structures of a range of intrinsic and extrinsic defects in black phosphorus (BP) are calculated using Density Functional Theory (DFT) and a hybrid density functional. The results demonstrate that energy barriers to form intrinsic defects, such as Frenkel pairs and Stone–Wales type defects, exceed 3.0 eV and their equilibrium concentrations are likely to be low. Therefore, growth conditions and sample preparation play a crucial role in defect chemistry of black phosphorus. Mono-vacancies (MV) are shown to introduce a shallow acceptor state in the bandgap of BP, but exhibit fast hopping rates at room temperature. Coalescence of MVs into di-vacancies (DV) is energetically favourable and eliminates the band gap states. Thus MVs are not likely to be the main contributor to p-doping in BP. Extrinsic defects are a plausible alternative, with Sn<sub>p</sub> found to be the most promising candidate. Other defects considered include I, O, Fe, Cu, Zn and Ni in surface adsorbed, intercalated and substitutional geometries, respectively. Furthermore, BP was found to be magnetic for isolated MVs and Fe doping, motivating further research in the area of magnetic functionalisation.

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## 1 Introduction

Black Phosphorus (BP) has been the subject of intense research in the past few years, since it was rediscovered as a 2D material. Its layered structure with 2D sheets held together by van der Waals (vdW) forces allows exfoliation of single and multi-layer BP flakes. Applications exploiting BP's unique properties include photo-catalysis,<sup>1–3</sup> semiconductors,<sup>4</sup> rechargeable batteries<sup>5,6</sup> and gas sensors.<sup>7</sup> BP has a narrow, tunable band-gap and absorbs light in the visible through to IR spectral region. As a layered 2D material, it exhibits a change in physical properties going from bulk crystal to the nano-scale single layer limit: the bandgap opens from 0.3 eV for bulk BP to 1.5 eV for a single layer due to the suppression of interlayer interactions.<sup>8</sup> Similar to graphene, BP has very high charge carrier mobilities of up to 200–1000 cm<sup>2</sup> V<sup>−1</sup> s<sup>−1</sup> and displays anisotropic behaviour along the  $\Gamma$ -X and  $\Gamma$ -Y principal directions in many of its properties.<sup>9</sup> However, due to lone pairs pointing outwards from the surface, BP is highly reactive with oxygen, which makes its properties sensitive to ambient conditions.<sup>10,11</sup> The rapid oxidation of BP can be prevented by capping layers,<sup>12,13</sup> and thus the stability and performance for future applications depends on intrinsic defects such as point

defects, line defects and impurities. The development of novel devices is mostly hindered by the lack of understanding of defects and defect creation.<sup>14</sup>

For example, BP was found to be p-doped, but the source of the doping is unknown. In particular, scanning tunnelling spectroscopy (STM) measurements attributed p-doping to shallow acceptor states induced by mono-vacancies.<sup>15</sup> Such shallow hole states are also attributed to observed defects on the BP surface in STM experiments.<sup>14,16,17</sup> Recently, Sn doping was suggested as an alternative source of p-doping in BP.<sup>18</sup> Sn, along with iodine and some transition metal (TM) elements, was detected in plasma mass spectroscopy at significant concentrations.<sup>19</sup> Their presence was found to alter the properties of BP; for example Fe impurities were reported to increase catalytic activity upon hydrogen evolution reactions and Ni impurities change the voltammetric signature of BP.<sup>19</sup> However, no description of how these species get incorporated and which configuration they adopt in the crystal had been given. This highlights the need to further study point defects and dopants in BP in order to determine the source of p-doping as well as characterise the nature of observed surface defects.

In this study we used DFT in conjunction with a hybrid functional to investigate a wide range of intrinsic and extrinsic point defects in BP. Intrinsic defects considered included mono-vacancies (MV) and di-vacancies (DV) as well as Stone–Wales (SW) defects and self interstitials. Further, we studied the stability and dynamics of MVs, to check the feasibility of their existence at large concentrations at room temperature. A

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number of extrinsic defects was simulated in various conformations (surface adsorbed, substitutional and intercalated) to study their impact on the electronic structure of BP. Impurity species were chosen based on reports of their detection in experimental measurements.<sup>19</sup> Besides Sn and I, which are used as catalysts to grow BP, TMs (Fe, Ni, Cu, Zn) were investigated and a brief analysis of magnetic properties of Fe and Ni defects is also given. Our results show the dependence of defect geometries and their electronic signature on the number of BP layers and will provide a theoretical background to support future experiments.

## 2 Methods

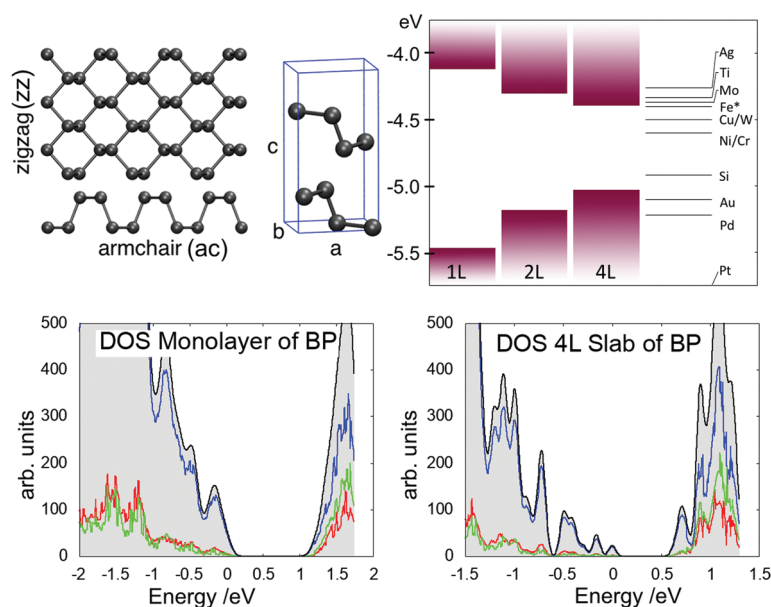
The calculations were performed using the CP2K code,<sup>20</sup> which employs a mixed Gaussian and plane wave basis-set (GPW). The DZ\_MOLOPT\_GTH basis set was used together with Goedecker–Teter–Hutter (GTH) pseudopotentials.<sup>21</sup> The plane wave cutoff was converged at 400 Ry, SCF convergence was set to  $10^{-6}$  a.u. and residual forces on atoms were smaller than  $0.01 \text{ eV } \text{\AA}^{-1}$ . Since GGA functionals predict a metallic behaviour for BP,<sup>8</sup> the PBE0-TC-LRChybrid functional<sup>22</sup> was used with a cutoff radius of 2 Å and 10% HF exchange. In order to reduce the computational cost of the hybrid functional calculations, the auxiliary density matrix method (ADMM)<sup>23</sup> was used, which uses a reduced basis set for the HF exchange calculation and thus allows cells up to 1500 atoms large to be calculated.

The bulk properties were calculated using a 1296 atom cell ( $9 \times 9 \times 2$  supercell) and a BP monolayer was modelled using a

324 atoms cell ( $9 \times 9$  surface supercell). All calculations were performed at the  $\Gamma$  point of the Brillouin zone. The optimised unit cell parameters were found to be  $a = 3.368 \text{ Å}$ ,  $b = 4.548 \text{ Å}$  and  $c = 10.87 \text{ Å}$  (see Fig. 1), in good agreement with experiment and other DFT studies.<sup>24–29</sup> All slab calculations included a 20 Å vacuum gap between periodically repeated images to minimise interactions across the periodic boundary. Since dispersion forces are poorly reproduced in DFT, Grimme-D3 vdW corrections<sup>30</sup> were applied in order to get the correct interlayer separation. The bandgap for 4L slab of BP was calculated to be 0.5 eV, which increased to 1.22 eV for a monolayer, as illustrated in the DOS plots in Fig. 1. The valence band edge displays mostly  $p_z$  orbital character, which is why the bandgap is very sensitive to interlayer interactions.

Intercalation energies were calculated for a four layer slab consisting of 1296 atoms ( $9 \times 9 \times 2$  supercell and 20 Å vacuum gap), where the intercalated species was placed in various geometries between the second and third layer. The cohesion energy of a P atom in a monolayer of BP is 3.255 eV, in good agreement with the textbook value of 3.275 eV,<sup>31</sup> which translates into a P–P bond energy of 2.170 eV.

To aid energy band alignment with substrates and STM tips affecting the charge state of defects, the position of the top of the valence band with respect to vacuum level was calculated as illustrated in Fig. 1. For a monolayer the VBM is at  $-5.5 \text{ eV}$ , and shifts up to  $-5.2 \text{ eV}$  for a bilayer and  $-5.0 \text{ eV}$  for a 4 layer slab. Depending on the defect level, tip potential and applied bias the charge state of a defect can be switched, inducing a change in its electronic and geometric structure. Charge transition levels (CTLs) are calculated using defect formation energies as a function of the Fermi level position.



**Fig. 1** Top left: Black phosphorus monolayer and unit cell structure illustrating the lattice directions. Top right: Position of the band edges with respect to the work-function of common metals (\* stainless steel). Bottom left: Total DOS of monolayer BP (grey) and projections on s-orbitals (red), p-orbitals (blue) and d-orbitals (green). Bottom right: Total DOS of multilayer BP (grey) and projections on s-orbitals (red), p-orbitals (blue) and d-orbitals (green).



Defect formation energies (DFE) are calculated using:

$$E_{\text{DFE}} = E_{\text{defect}}^q - E_{\text{pristine}} + \sum_i \mu_i N_i + qE_f + \Delta V, \quad (1)$$

where  $q$  denotes the charge state of the defect,  $\mu$  is the chemical potential of any species that has been added or removed from the system,  $N$  is the number of exchanged atoms,  $E_f$  is the Fermi level of the pristine system and  $\Delta V$  denotes a potential alignment correction.

Two P chemical potentials were used: the potential of a P atom in a monolayer of BP ( $\mu_{\text{P}} = -179.23$  eV) and the chemical potential of an isolated P atom in vacuum ( $\mu_{\text{P}} = -175.98$  eV). The first is used in all previous studies summarised in Table 1. The second provides a more intuitive understanding of energies involved in breaking and creating bonds in the BP monolayer and in several layers. Since all atom positions are equivalent by symmetry, the average energy per atom can be used as P chemical potential. The difference in energy per P atom between bulk and monolayer BP is less than 0.05 eV, showing that calculated DFEs have a small dependence on choice of BP reference. Chemical potentials for iodine and oxygen were calculated as half of the energy of a  $\text{I}_2$  and  $\text{O}_2$  (triplet) molecules. For Sn and TMs the energy of an isolated atom in vacuum was used for the chemical potential. These potentials were chosen since they most resemble the conditions under crystal growth, during which impurities are incorporated – oxygen and iodine exist in their molecular form, whereas the metals are considered as isolated gaseous atoms. To calculate the incorporation energies of substitutional defects, the chemical potential of the substituted P was chosen as the energy of a P atom in monolayer BP. Thus, the incorporation energy reflects a process during crystal growth, where the substituted P atom can be moved to a new P lattice site.

**Table 1** Defect formation energies in eV of intrinsic defects in monolayer BP calculated using two P chemical potentials:  $\mu_{\text{P(ML)}}$  refers to a P atom in a monolayer of BP,  $\mu_{\text{P(gas)}}$  refers to an isolated P atom in vacuum. Reported values in literature use  $\mu_{\text{P(ML)}}$ , therefore DFEs with the same chemical potential were calculated in column 2

Defect	$\mu_{\text{P(ML)}}$	$\mu_{\text{P(gas)}}$	Literature
59 MV	1.81	5.07	1.63, <sup>33</sup> 1.65, <sup>24</sup> 1.71 <sup>26</sup>
5656 MV	2.38	5.3	2.05, <sup>24</sup> 2.0 <sup>26</sup>
$P_i$	1.91	−1.35	1.79 <sup>33</sup>
$P_{\text{ads}}$	1.56	−1.69	1.6 <sup>34</sup>
5757 DV	1.51	8.02	1.35 <sup>24</sup>
585-A DV	1.70	8.21	1.36, <sup>33</sup> 1.41, <sup>24</sup> 1.77 <sup>26</sup>
555777 DV	2.85	9.36	2.28, <sup>24</sup> 2.76 <sup>26</sup>
5555-6-7777 DV	1.93	8.44	1.54 <sup>24</sup>
5959 DV	3.45	9.96	
585-B DV	3.93	10.44	3.29, <sup>24</sup> 3.2 <sup>26</sup>
949 DV	3.65	10.16	
4-10-4 DV	2.02	8.53	2.27 <sup>26</sup>
SW 1	1.8 <sup>a</sup>	1.8 <sup>a</sup>	1.4, <sup>33</sup> 1.62, <sup>26</sup> 1.32 <sup>16</sup>
SW 2	0.9 <sup>a</sup>	0.9 <sup>a</sup>	1.22, <sup>26</sup> 1.01 <sup>16</sup>
Frenkel (MV + $P_i$ )	3.38 <sup>a</sup>	3.38 <sup>a</sup>	
Frenkel (MV + $P_{\text{ads}}$ )	3.08 <sup>a</sup>	3.08 <sup>a</sup>	

<sup>a</sup> Independent of phosphorus chemical potential.

Potential alignment in these calculations is important, since the average electrostatic potential is set to zero in DFT calculations and thus, in order to compare energies between different systems, a shift in potential between different calculations needs to be corrected for. Charge corrections were performed by running 2D periodic simulations and extrapolating defect formation energies to the  $N \rightarrow \infty$  limit using cell sizes from  $5 \times 5$  up to  $18 \times 18$  surface unit cells (see ESI†).

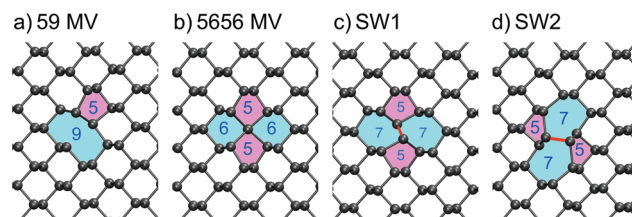
## 3 Results of calculations

### 3.1 Intrinsic defects

The main types of intrinsic point defects in BP – MVs, DVs, Stone–Wales defects and self-interstitials, will be discussed in this section. An overview of DFEs is given in Table 1 along with reported values from literature. The positions of the Kohn–Sham (KS) defect states in the band gap of a monolayer and multilayer BP are shown in Fig. 3. Line defects, such as grain boundaries, dislocations and step edges, will not be discussed in this report.

**3.1.1 Mono-vacancies.** Fig. 2a illustrates the lowest energy neutral MV structure with a formation energy of 5.07 eV. Upon creation of the MV, three bonds are being broken, which costs 6.51 eV. The atoms around the defect relax to compensate two of these bonds, reducing the DFE of the MV. This leaves one dangling bond on a two-coordinated P atom, creating an unoccupied state in the band-gap of monolayer BP about 0.4 eV above the VBM (see Fig. 3).

To investigate the electronic structure of MV, the Inverse Participation Ratio (IPR) method was used. This helps to analyse the degree of localisation and nature of defect states, with higher IPR values corresponding to higher degree of localisation of one-electron state (see the detailed description in ESI†). The IPR analysis reveals that the defect induced bandgap state is localised on the under-coordinated P atom creating a peak in the IPR spectrum. The band edge states remain delocalised as is indicated by a small IPR value. A positively charged and negatively charged vacancy were also considered and their formation energy diagram is given in ESI.† In monolayer BP, the neutral MV is the lowest energy state for Fermi levels below 0.55 eV above the VBM, after which the negative charge state becomes energetically more favourable.



**Fig. 2** Defect structures in monolayer BP with their respective formation energies given above: (a) Neutral (5|9) phosphorus MV. (b) Negatively charged (55|66) MV. The central P atom is four coordinated in a  $\text{sp}^3\text{d}^2$  hybridisation state. (c + d) Stone–Wales defects.



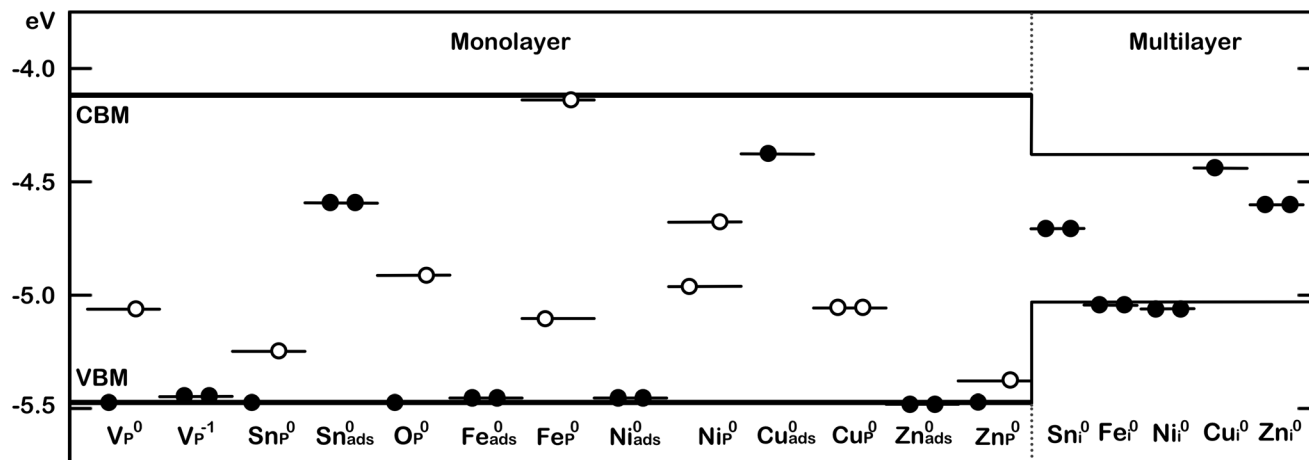


Fig. 3 Schematic illustrating the defect induced Kohn-Sham states in the bandgap of BP. Filled circles indicate a filled state and empty circles an empty state, while a circle on the right/left indicates the spin up/down channel. All energies are referenced to the vacuum level (0 eV). The states for adsorbed O atom are deep in the valence band and are not shown.

However, in bulk BP the negatively charged MV is most stable for all Fermi level positions.

The work-function of common metals relative to the bands of BP is indicated in Fig. 1. In recent reports Ti and Au were used as electrode contacts,<sup>12,32</sup> which align with the VBM (Au) and the CBM (Ti). Thus, in order to establish a common Fermi level, band bending can cause defects in the vicinity of the contacts to adopt different charge states. Charged defects are also linked to lower device performance of field effect transistors made from BP and Ti/Au contacts.<sup>4</sup> Particularly for thin BP flakes, contact with the metal substrate can shift the Fermi level position, thus inducing a change in the charge state of the MV.

The negatively charged MV adopts a significantly different geometry from the neutral state shown in Fig. 2b, where a P atom becomes  $sp^3d^2$  hybridised and binds to four neighbouring P atoms, passivating all dangling bonds. The  $sp^3d^2$  hybridisation is commonly observed for negatively charged phosphorus compounds such as  $PF_6^-$ , which allows four in-plane bonds with bond angles close to  $90^\circ$ . In this geometry, the four coordinated P atom sits between the top and the bottom row. There is now no acceptor state in the bandgap and the defect induced states, which appear at the band edges, show a more localised character (see Fig. 3). The IPR analysis of these states is shown in Fig. S1 in ESI.† The localised state in the conduction band can be attributed to an anti-bonding state between the four-coordinated P atom and its four nearest neighbours. The localised state near the VBM is a non-bonding state and the localised state deeper into the valence band is a bonding state between the four-coordinated atom and its four nearest neighbours. The additional potential of the negative charge leads to more localisation of deeper band states as well, which is due to constraints of the simulation cell. We note that the IPR analysis allowed us to easily identify defect-induced localised states, which would otherwise be a tedious manual checking process through all states.

The DFE for MV in a four layer slab was also calculated and the trend as the vacancy is moved into the slab investigated. While the DFE for a MV at the surface of the slab was calculated at 5.01 eV, the DFE for a MV in the second layer is 4.99 eV, which almost recovers the bulk value of 4.97 eV. The difference in formation energies for MV at the surface compared to the bulk crystal is not substantial enough to infer large differences in vacancy concentrations and vacancy aggregation at the surface can be ruled out. Thus, vacancies are expected to be distributed evenly throughout the crystal, ignoring the role of line defects in vacancy trapping.

**3.1.2 Di-vacancies.** Due to the covalent bonding in BP, many DV structures exist, where two phosphorus atoms are missing in close proximity creating a bigger defect complex. The most energetically stable DV structure is shown in Fig. 4a.

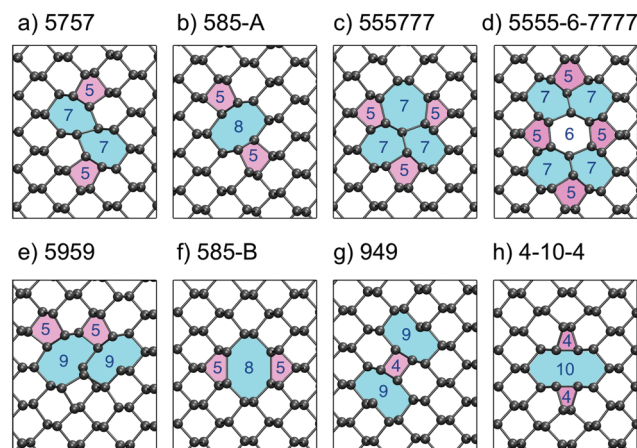


Fig. 4 (a–h) The eight lowest energy DV structures in monolayer BP; their respective formation energies are shown in Table 1. The rings are labelled according to how many atoms make up the ring structures and are coloured as a visual aide.



As in the MV case, the atoms next to the empty lattice sites relax in order to compensate dangling bonds and form a 5757 defect structure such that all atoms become three coordinated. The labelling is adopted from graphene and signifies how many members constitute the defecting structures (see Fig. 4). Interestingly, a 5757 DV has a much lower DFE at 8.02 eV than a sum of two MVs and thus two mobile MVs are expected to coalesce to form the DV.

Apart from the 5757 vacancy, several other metastable structures were found and are shown in Fig. 4b–h. The 585-A DV has a DFE close to the 5757 one at 8.21 eV and is also more stable than two isolated MVs. Previously, this vacancy was reported to be the most stable DV structure,<sup>16,33</sup> but recent reports<sup>16,24</sup> as well as this work support the observation, that the 5757 structure is lower in energy. The 555777 DV shown in Fig. 4c represents a more complex DV structure and with a formation energy of 9.36 eV is still more favourable than two separate vacancies. Similar to structures a and b the atoms relax to compensate any dangling bonds created during the vacancy formation such that all atoms are three-coordinated. The 5555-6-7777 DV is very similar to the 555777 one and differs in just a rotation of a P–P bond, similar to a Stone–Wales defect. This DV configuration was found to have a lower formation energy of 8.44 eV.

We note that the ordering of the defect structures compares well with previous results,<sup>16,24</sup> however, values of DFE in the second and forth column of Table 1 show small differences. These may result from different DFT functionals used, calculation set-up, basis set and code. Furthermore, BP is considered to be “soft” due to its low Young’s modulus (166 GPa and 44 GPa along *zz* and *ac*, respectively) and thus strain due to defects in relatively small simulation cells and electrostatic interactions between periodically translated defects can lead to observed shifts in calculated formation energies. Finally we note that the lowest energy di-vacancies do not create KS states in the band gap.

**3.1.3 Other intrinsic defects.** Besides MVs and DVs, BP can also exhibit other structural defects, such as Stone–Wales-like defects or self-interstitials shown in Fig. 2c + d. An extra P atom adopts an interstitial position between a P atom on an upper zigzag and a P atom on a lower zigzag by breaking the up-down P–P bond and is thus two fold coordinated. The formation energy of a  $P_i$  is  $-1.69$  eV in a monolayer. Since one bond is broken and two new ones are formed, the energy can be compared to a P–P bond energy of 2.17 eV in pristine BP. The difference of 0.48 eV is attributed to surface deformation around the interstitial. Interestingly, the adsorption energy of a P adatom on a BP monolayer is lower than that of the self-interstitial by about 0.3 eV and thus, given the activation energy can be overcome, P interstitials will be converted into P adatoms. The barrier for P adatom diffusion along the [010] direction (*zz* direction, see Fig. 1) is only  $\sim 0.15$  eV, leading to fast diffusion across the surface at room temperature. Thus, surface adatoms can potentially passivate surface MVs or DVs. The aggregation of several P adatoms into bigger clusters should be favourable but was not investigated here.

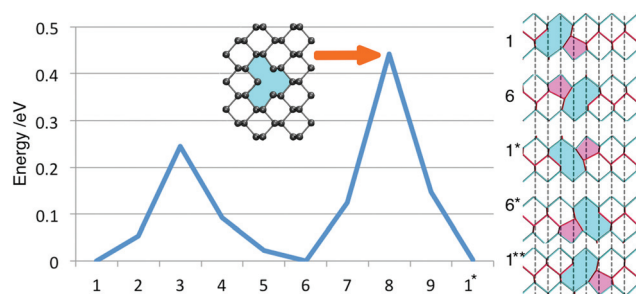
Stone–Wales defects have previously been reported for graphene<sup>35,36</sup> and theoretical calculations predict their existence in BP as well.<sup>26,33</sup> SW defects require a change in connectivity of two atoms *via* a rotation of a P–P bond, which is highlighted in red in Fig. 2c + d. The formation energy of SW1 defect is 1.81 eV and of SW2 defect is 0.9 eV, which, unlike the MV case, does not rely on the choice of chemical potential for P since no atoms are added or removed, and thus can be compared to other theoretical calculations. Reported values for the SW1 defect range from 0.84 eV to 1.62 eV,<sup>16,26,33,37</sup> highlighting a large spread in calculated DFEs, which arises from different DFT functionals, codes and calculation parameters (*e.g.* super-cell size). The SW2 defect has the lowest DFE of the intrinsic defects considered and is thus expected to be the dominant defect formed.

In order to investigate the formation mechanism of SW defects, nudged elastic bands calculations (NEB) were performed. The forward barrier to form a SW1 defect is 3.08 eV and 2.17 eV for SW2 defect and the reverse barriers are 1.27 eV and 1.25 eV for both SW defects, respectively.

Combining the DFE for a MV and a P self-interstitial results in a Frenkel pair formation energy of 3.38 eV. This energy for MV and a surface adatom is 3.08 eV. These energies are also independent of the choice of chemical potentials used and can be directly compared to the formation energy of a Stone–Wales defect. At equilibrium conditions Frenkel defects are less favourable than SW defects.

We note that formation barriers for both SW and Frenkel defects are too high for them to be formed in high concentrations at room temperature. Instead, they can be created under high-temperature non-equilibrium growth conditions.

**3.1.4 Vacancy diffusion.** Since some DVs are more stable than pairs of MVs in monolayer BP, they can form upon collision of two diffusing MVs. In order to study the diffusion barrier and consequently the rate of diffusion of MVs in monolayer BP, nudged elastic band calculations (NEB) were performed. In Fig. 5 the diffusion barrier is plotted for a neutral



**Fig. 5** Diffusion barrier for a neutral MV along the *zz* direction in monolayer BP. The inset shows the transition point geometry. On the right, the geometry of the vacancy at each minima in the diffusion path is illustrated. Note the asterisk signifies a commensurate structure translated by half a unit vector and two asterisks denote a commensurate structure after translation by a whole unit vector. Red lines represent the upper and blue lines the lower zigzag. The 5 and 9 member rings are coloured in pink and cyan as a visual aid.



vacancy diffusing along the *zz*-direction. As previously reported in ref. 24, diffusion of MVs was confirmed to be a two step process, however, the absolute barrier height for the same diffusion path was found to be about 0.1 eV larger. The first diffusion step involves a change in connectivity in the upper zigzag by moving a P atom 0.9 Å along the *zz*-direction and has an associated barrier of 0.25 eV (going from configuration 1 to 6 in Fig. 5). The rate determining process involves a change of connectivity in the lower zigzag and has a higher barrier of 0.44 eV associated with it. Going from configuration 1 to 1\* corresponds to a translation of the vacancy by half a surface unit vector along *zz* and from 1 to 1\*\* corresponds to a translation of the vacancy by one whole unit vector.

As shown in the inset, the transition state structure is different to the symmetric structure found for the negatively charged vacancy (Fig. 2b). In the latter case, the central P atom becomes four-fold coordinated and sits in between the upper and the lower zigzag. The transition structure, however, does not show this relaxation of the central P atom and instead resembles an unrelaxed MV. In fact the four-fold coordinated geometry in its neutral charge state would be 0.1 eV higher in energy than the transition structure, which is in good agreement with ref. 24.

Interestingly, the diffusion barrier remains unchanged for a positively charged vacancy but is significantly reduced for a negatively charged vacancy. Due to the different bonding behaviour of the negative vacancy, the barrier for diffusion is lowered to ~0.07 eV along the *zz*-direction. Hence a negatively charged vacancy is expected to be significantly more mobile than a neutral or positively charged vacancy.

The calculated diffusion barriers  $E_B$  can be translated into hopping rates  $\nu$  using an Arrhenius equation:

$$\nu = \nu_0(T) \exp(-E_B/k_B T), \quad (2)$$

where  $\nu_0$  denotes a pre-factor related to the hopping distance and attempt frequency as a function of temperature  $T$  and  $k_B$  is the Boltzmann constant. The pre-factors were calculated by Cai *et al.*<sup>24</sup> employing the Vineyard method, which uses vibrational analysis to estimate attempt frequencies. Using eqn (2) the hopping rates of a MV calculated at temperatures of 10 K, 70 K and 300 K are shown in Table 2. These three temperatures correspond to typical experimental conditions. At 10 K a MV in a monolayer of BP will be practically immobile as hopping rates for all three charge states are very low. Thus, these vacancies would be stable enough to be imaged using

**Table 2** Parameters used in the calculations of hopping rates for neutral and negatively charged MV along *zz*-direction in monolayer BP. The prefactors were adopted from Zhang *et al.*<sup>24</sup>

Temperature/K	Prefactor/s <sup>-1</sup>	Neutral MV Hopping rate/s <sup>-1</sup>	Negative MV Hopping rate/s <sup>-1</sup>
300	$1.63 \times 10^{11}$	$4.49 \times 10^3$	$1.09 \times 10^{10}$
70	$3.81 \times 10^{10}$	$1.34 \times 10^{-19}$	$9.98 \times 10^5$
10	$5.44 \times 10^9$	$1.30 \times 10^{-324}$	$2.18 \times 10^{-41}$

scanning probe techniques such as Atomic Force Microscopy (AFM) or STM. At 70 K the hopping rate for a positively charged or neutral vacancy is of the order  $10^{-19} \text{ s}^{-1}$  and the vacancies will still be immobile in experimentally relevant time scales, however, the hopping rate of a negatively charged vacancy is about one million hops per second and thus this vacancy is too mobile to be observed in scanning probe measurements. At room temperature, both vacancy states show very fast hopping rates, thus MVs will be diffusing at high rates on the surface of BP and coalesce into DVs upon collision. The defect concentration observed in STM is around 60 ppm,<sup>14</sup> which is roughly one defect every 80 lattice sites. At hopping rates of the order  $10^3 \text{ s}^{-1}$ , the probability of two MVs colliding rapidly converges to one, as the diffusion process can be treated as a Markov chain. Assuming diffusion is a random walk with RMS displacement of  $\sqrt{N}$  ( $N$  = number of hops) one can easily deduce that at room temperature on average it takes two seconds for two MVs to collide.

### 3.2 Extrinsic defects

Impurities are often present in BP films and have been suggested as an alternative explanation for defects observed in STM.<sup>18</sup> Tin, which is used as a catalyst during the growth of BP crystals together with iodine, is detected in significant concentrations in XPS and inductively coupled plasma mass spectrometry (ICP-MS) measurements, as well as Ni, Zn, Fe and Cu in lower concentrations.<sup>19</sup> These impurities were investigated here in a substitutional, intercalated and surface adsorbed geometries and their formation energies are summarised in Table 3.

Tin and iodine are used as catalysts during the crystal growth and constitute the two main impurities, besides oxygen. Thus a more detailed description of these defects is given below.

**3.2.1 Iodine defects.** Iodine adsorbs on the surface 2.74 Å above a P lattice site with an adsorption energy of 0.30 eV. Since the I chemical potential was chosen to be half of the energy of I<sub>2</sub> molecule, the positive adsorption energy indicates it is unfavourable to break the I–I bond and adsorb on BP.

Iodine was also investigated as a substitutional defect. It costs 1.39 eV to incorporate an I atom instead of lattice P, if

**Table 3** Formation energies for experimentally observed impurity elements in adsorbed (ML), substitutional (ML) and intercalated geometries (centre of 4L slab). Negative energies correspond to the energy gain in the process considered

Summary of defect formation energies/eV			
Element	Adsorbed Energy/eV	Substitutional Energy/eV	Intercalated Energy/eV
O	−2.00	−0.38	−1.91
I	0.30	1.39	2.47
Sn	−2.76	−3.28	−1.82
Fe	−2.25	−2.52	−2.57
Ni	−3.07	−2.62	−3.93
Cu	−1.96	−2.20	−2.85
Zn	−0.20	−0.49	−0.17



the chemical potential of P in a BP monolayer is used as a reference.  $I_P^0$  binds to the 2 coordinated P atom in a P vacancy and sticks out of the surface plane (see Fig. 6). The gain in energy by forming the I–P bond is about 0.4 eV. This is in good agreement with the strength of P–I bond in  $PI_3$ .<sup>38</sup> The neutral charge state was found to be lowest in energy for all Fermi level positions throughout the bandgap and no bandgap states were created upon forming this defect. Bader analysis shows almost no charge transfer between iodine and the BP lattice, indicative of a covalent bond between P and I.

Furthermore, the intercalation energy for a single iodine atom was calculated at 2.47 eV. The relatively large I atom is not favourable to intercalate between the BP layers due to electronic overlap resulting in large lattice distortions. Whether a larger I concentration can lead to a change in interlayer spacing or a change in stacking order as has been reported for Na intercalation<sup>39</sup> was not investigated. Finally, we note that these I-related defects do not create KS states in the BP band gap.

**3.2.2 Oxygen defects.** Oxygen was also investigated due to its role in the degradation reactions of BP. A single O atom can bind to the lone pair of a P surface atom with a strong binding energy of  $-2.01$  eV. It adopts a configuration in which the O atom sticks out of the surface plane with a P–O double-bond length of  $1.49$  Å, as illustrated in Fig. 6.

Only slightly smaller is the intercalation energy of an O atom at  $-1.91$  eV, where, similarly to surface adsorption,

O binds to a lone pair of a P atom with the same bond length of  $1.49$  Å. The difference in energy comes primarily from lattice distortions around the intercalated O atom in order to accommodate it between the 2D layers.

Comparatively less favourable is the substitution of a lattice P atom, which for a ML was calculated at  $-0.38$  eV. The two-valent O atom can bind to one P atom of the upper row and one of the lower row, which constitutes the lowest energy configuration, or it can bind to two P atoms in the same row, which is  $0.33$  eV higher in energy. In both cases, a dangling bond is created, which introduces a bandgap state about  $0.5$  eV above the VBM (see Fig. 3), making substitution less favourable. For these calculations the reference chemical potential of oxygen was chosen as half of the energy of  $O_2$  molecule in its triplet state in vacuum. Thus the negative interaction energies corroborate with experimentally observed high reactivity of BP with molecular oxygen.<sup>40</sup>

**3.2.3 Tin defects.** Fig. 6 illustrates a  $Sn_P$  defect geometry. Unlike an iodine defect, the lattice around the substitutional tin atom is perturbed very little, as Sn occupies a P lattice site with a slight relaxation of about  $0.3$  Å out of the surface plane. Since Sn is  $sp^3$  hybridised and therefore four-valent and P is five-valent, a hole is induced at  $0.2$  eV above the VBM (see Fig. 3). IPR analysis reveals the hole is localised on the Sn atom, which is bonded to two upper layer P atoms and one P atom in the lower layer in a distorted tetrahedral configu-

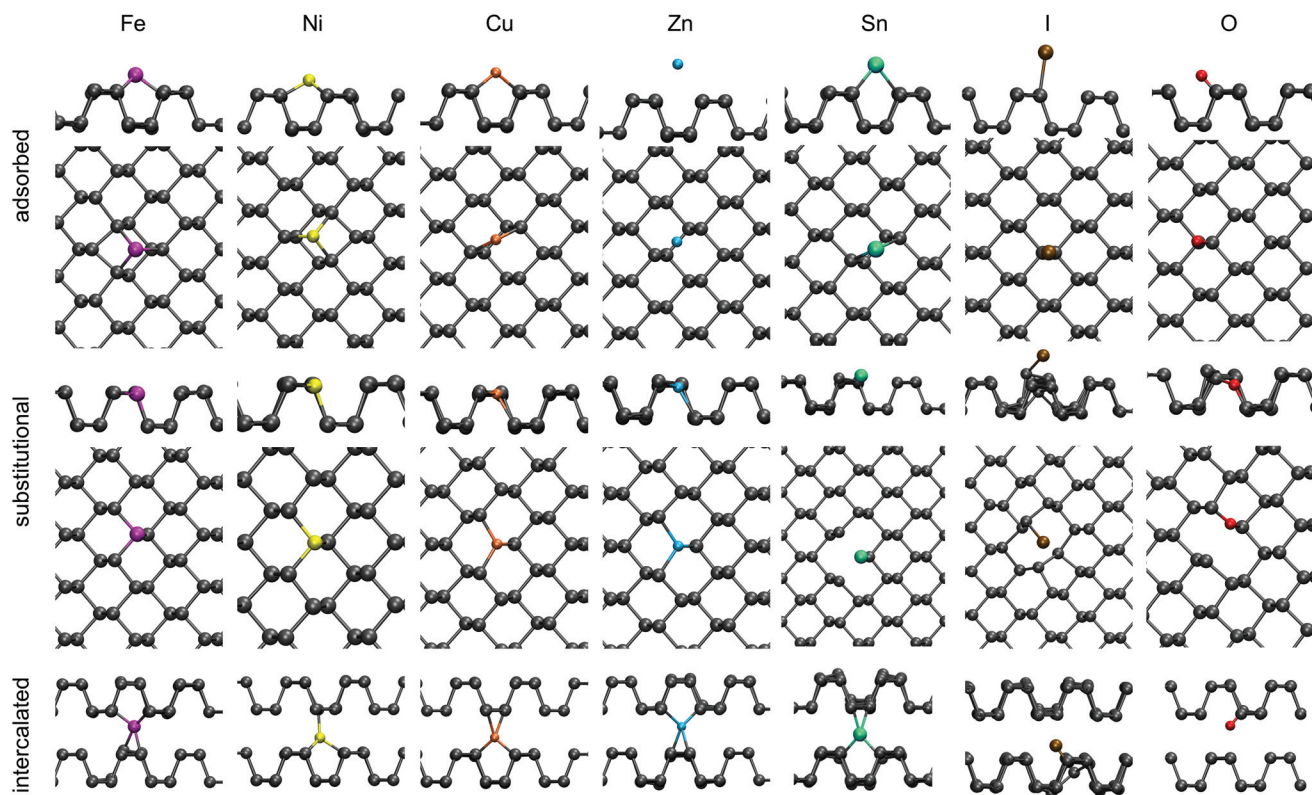


Fig. 6 Summary of impurity defects in BP (P is grey). Geometries are shown for Fe (magenta), Ni (yellow), Cu (orange), Zn (cyan), Sn (green), I (brown) and O (red) in adsorbed (top), substitutional (middle) and intercalated (bottom) configurations.



ation. The defect formation energy was calculated to be  $-3.28$  eV for a neutral  $\text{Sn}_\text{P}$  and a CTL from neutral to the  $-1e$  charge state was found at  $0.33$  eV above the VBM (see Fig. S4 in ESI†). Since the P chemical potential is P in monolayer BP, the DFE can be compared to the cohesion energy of a P atom in BP, which is  $-3.25$  eV. Since these two energies are very close, we predict  $\text{Sn}_\text{P}$  defects to form readily, given Sn atoms are present in the system.

To gain insight into the defect behaviour as it is moved into the slab approaching the bulk limit, substitutional Sn impurities were investigated at various depths in a four layer slab. A four layer slab consisting of 1296 atoms was doped with a single Sn atom in the upper row of the top layer, in the bottom row of the topmost layer and similarly in the second layer. The defect formation energy decreases slightly as the Sn impurity is moved into the slab. An impurity in the top row of the top layer has a DFE of  $-3.50$  eV, while the DFE for the second layer was reduced to  $-3.56$  eV, indicating that substitution is slightly favoured as the defect is moved into the bulk compared to the defect at the surface or in a monolayer. A substitutional Sn in the top row of the top layer creates an acceptor state  $0.15$  eV above the VBM, which moves to  $0.12$  eV for the bottom of the top layer and ultimately to  $0.05$  eV for substitutional Sn in the top row of the second surface layer. This illustrates that the acceptor state becomes shallower as the defect approaches the bulk limit than that on the BP surface.

Adsorption of Sn was found to be less favourable than substitution, with an adsorption energy of  $-2.76$  eV. Sn adsorbs  $1.95$  Å above the surface on top of a valley site, binding to two surface P atoms. A donor state is created in the bandgap of BP  $0.43$  eV below the CBM, as indicated in Fig. 3.

Lastly, intercalated Sn was investigated, with the atom placed at various positions between the second and third layer of a four layer BP slab. Sn adopts a four-valent geometry, bonding to two P atoms of the upper and lower layer, respectively. However, the BP lattice displays large displacements around the intercalated Sn, resulting in a DFE of  $-1.82$  eV. A donor state is induced in the bandgap of BP,  $0.26$  eV below the CBM (see Fig. 3), which is localised on Sn. Thus, substitutional Sn acts as an acceptor, while adsorbed and intercalated Sn act as electron donors.

**3.2.4 Transition metal defects.** Finally, four transition metals (TM) were considered, namely Fe, Ni, Cu and Zn. TMs have been reported in significant concentrations in BP samples and are prime candidates for magnetic functionalisation of BP.<sup>41,42</sup> A recent experimental report found Fe-doped BP samples ( $\text{Fe}_{5\%}\text{P}_{95\%}$ ) to exhibit paramagnetism at room temperature.<sup>41</sup> However, no structural information elucidating how Fe had been incorporated into BP was given. Thus, TM impurities were investigated in three configurations: adsorbed on a monolayer, as a substitutional defect in a monolayer and intercalated between the second and third layer in a four layer slab. Formation energies of these configurations are summarised in Table 3 and optimised geometries can be found in Fig. 6.

Intercalated TMs constitute the lowest energy configuration for the open shell elements Fe, Ni and Cu, while the closed

shell Zn preferentially sits in a substitutional configuration. Upon intercalation the 4s electrons of Fe and Ni get promoted to the 3d orbitals, but for Cu and Zn the 3d shell is already completely filled and thus electrons populate the radially more extensive 4s orbital.

This rearrangement of electrons leads to changes in the magnetic moment of Ni and Fe. Since the 4s electrons completely fill the 3d orbitals in Ni defects, Ni adopts a low spin state with  $\mu_\text{B} = 0$ . Similarly Fe changes from  $\mu_\text{B} = 4$  to a  $\mu_\text{B} = 2$  state, where the  $S = 5$  state is  $0.24$  eV and the singlet state is  $0.6$  eV higher in energy than the triplet state. Thus  $\text{Fe}_\text{i}$  is predicted to possess a magnetic moment of  $2\mu_\text{B}$  at low temperatures. Whether the spin arrangement for higher TM concentrations leads to different magnetisation was not investigated in this work. Therefore, the results presented herein refer to low doping/impurity concentrations, where impurity atoms are dispersed. Cu induces a donor state in the bandgap of BP, which sits at the CBM and Zn induces a deep donor state  $0.33$  eV below the CBM. Ni and Fe, however, do not produce any bandgap states at all, as shown in Fig. 3.

Adsorbed Cu and Zn interact more weakly with BP compared to Fe and Ni as indicated by their higher respective DFEs. Cu adsorbs on a valley site between two P rows and binds to one P atom of each row with a bond length of  $2.21$  Å. In doing so a donor state is created at the CBM of BP. Zn also adsorbs in a valley site and binds to two surface P atoms with a bond length of  $2.95$  Å, but with a much reduced DFE of  $0.2$  eV. Fe does not exhibit the same bonding behaviour and instead binds to two P atoms of one row ( $2.27$  Å) and one P atom of a neighbouring row ( $2.18$  Å), sitting in a three co-ordinated valley site. Furthermore, as was observed for intercalated Fe, the triplet spin state is lower in energy than the singlet state, as the 4s electrons populate the 3d orbitals. The same can be observed for Ni, which also adsorbs in a three co-ordinated valley site with two  $2.20$  Å bonds to one P row and a  $2.11$  Å bond to the other.

Substitutional TM impurities adopt a P lattice site with a maximum relaxation of  $0.26$  Å along the armchair direction and  $0.05$  Å along the out of plane direction. Cu induces a deep acceptor state  $0.42$  eV above the VBM. This state is localised on the TM atom and its three nearest neighbour P atoms. The DFE for a  $\text{Cu}_\text{P}$  defect is  $-2.20$  eV. Zn in contrast has a higher DFE of  $-0.49$  eV and a small spin splitting of about  $0.1$  eV can be observed. This leads to an empty state in the beta (minor) spin channel at the top of the valence band, creating a shallow acceptor state. A larger spin splitting of  $0.25$  eV was found for the  $\text{Ni}_\text{P}$  defect. For both spin channels an acceptor state was created in the bandgap, which is  $0.52$  eV above the VBM in the spin up (major) channel and  $0.77$  eV above the VBM in the spin down (minor) channel. The DFE for  $\text{Ni}_\text{P}$  was calculated to be  $-2.62$  eV, the lowest of the TMs considered.

Lastly, a  $\text{Fe}_\text{P}$  defect was considered. An isolated Fe atom has a magnetic moment of  $\mu_\text{B} = 4$ , but upon incorporation into BP, the 4s electrons populate the 3d shell and the  $\mu_\text{B} = 2$  becomes lower in energy. This defect was found to have a DFE of  $-2.52$  eV. Interestingly, an empty state is created in the spin up



channel at 0.42 eV above the VBM, however, the corresponding spin down state is located at about 0.05 eV below the CBM.

It is important to note that spin splitting is very sensitive to how exchange interactions are calculated. For the calculations presented here, the proportion of exact Hartree–Fock exchange used in the density functional was fitted for a pristine BP monolayer and bulk properties and not to reproduce TM spin splitting.

## 4 Discussion

In order for BP to make the transition from research laboratories to everyday devices, its physical properties need to be better understood. In particular point defects play a crucial role in device stability and are still subject to extensive research. Furthermore, the introduction of extrinsic dopants can be used to functionalise BP for novel technological applications. Typically, concentrations of at least  $10^{18} \text{ cm}^{-3}$  are needed to observe doping in semiconductors and p/n-doped BP has been reported with doping concentrations of around  $10^{15} \text{ cm}^{-3}$ .<sup>43</sup> Experimentally observed p-doping has previously been attributed to MVs. However, the origin of the MVs is unclear. Their DFE is too high to be created thermally at large concentrations. MVs have low diffusion barriers and therefore can migrate and be captured by other point or line defects. Thus any MVs created during the crystal growth process have ample time to find a lower energy structure. We have shown that a MV can coalesce with another MV to form a considerably more stable DV, which does not have an acceptor state associated with it. To date there are no experimental reports of DVs on the surface of cleaved BP from scanning probe measurements, impugning the interpretation that MVs are the dominant defect.

At room temperature concentrations of thermally created defects such as Frenkel pairs and SW defects are expected to be low due to their high DFEs. Thus, observed defects in experimental studies are likely defects, which are grown in during the crystal growth process or sample anneal. Since this is a non-equilibrium process, determination of accurate chemical potentials and reaction pathways is difficult. Therefore, the calculated DFE give insight into which defects are likely, but cannot be used to derive accurate defect concentrations. For example the barrier for a SW2 defect to reform into pristine BP is 1.25 eV, which means at room temperature the rate of SW annihilation is low. A detailed experimental study of defects pre and post sample anneal could be informative to investigate recombination or defect annihilation processes.

As outlined above, experimental evidence for impurity species in BP is considerable. Our results show that iodine does not react strongly with BP as P–I bonds are weak. That phosphorus reacts weakly with iodine can also be seen in the low standard enthalpy of formation of  $-46 \text{ kJ mol}^{-1}$  (0.47 eV per molecule) for  $\text{PI}_3$ , a possible intermediate reactant during crystal growth. Thus we do not expect a large concentration of

I related defects in BP. Furthermore, Sn is typically added in excess to bind any iodine in  $\text{Sn(IV)I}_4$  and thus prevent reaction with BP.

Sn can be observed in XPS and ICP-MS and we have shown that substitutional Sn is the favoured configuration for Sn defects. In a BP monolayer, a shallow acceptor state 0.2 eV above the VBM is created, which moves closer to the band edge in a four layer slab. While most calculations are performed for a monolayer, most experimental data are obtained from bulk crystals or multilayer BP. Thus, our results highlight the need to consider not only monolayer systems, but also BP slabs to be able to compare with experiments directly. As the defect level becomes more shallow in multi-layer BP, it can get ionised thermally and thus creating hole carriers in BP which may be the source of observed p-doping, a process not possible for the deep acceptor state in monolayer BP.

Other dopants, which lead to p-doping are also presented: substitutional oxygen, substitutional and intercalated TMs and P self-interstitials. While most of these defects lead to p-doping, chemical analysis of BP crystals reveals an order of magnitude lower concentrations of TM elements compared to Sn.<sup>19</sup> Thus, these are not considered to be the main contributors to p-doping. Nevertheless, results on Fe doping indicate that magnetic BP can be achieved. A Fe surface adatom as well as substitutional and intercalated Fe will adopt a spin triplet state. Our calculations represent a disperse low density limit and the long range alignment of spin for higher defect densities was not investigated. However, it has been shown experimentally that Fe doped BP crystals exhibit para-magnetism at room temperature, indicating that no long range alignment into a ferromagnetic state takes place.<sup>41</sup>

Lastly, oxygen interacts strongly with the lone pairs of phosphorus, creating O adatoms and intercalated oxygen, while substitution is less favourable. Oxygen adatoms and interstitials do not contribute to p-doping of BP, since no hole states are created, but substitutional oxygen does. However, it is unclear how a large concentration of  $\text{O}_\text{p}$  defects could be created since they represent a meta-stable state almost 2 eV higher in energy than  $\text{O}_\text{ads}$  and  $\text{O}_\text{int}$ .

## 5 Conclusions

In summary, we characterised the geometric and electronic structure of intrinsic and extrinsic point defects in BP. DFE for Frenkel pairs are higher than those for Stone–Wales type defects, which are thus assumed to be the dominant intrinsic defect. However, their DFEs are too high to be created thermally in high concentrations. Thus, observed defects are predicted to be created during the crystal growth or sample preparation process. Since these are high temperature, non-equilibrium processes, defects with high DFEs can be grown in, leading to higher defect concentrations than would be expected from their DFEs.

MVs create an acceptor state in the bandgap, which is deep for a monolayer and becomes more shallow for multilayer



slabs. They were also shown to have a low diffusion barrier of 0.45 eV along the surface *zz*-direction, leading to fast vacancy hopping at room temperature and coalescence of MVs into DVs. Unlike MVs, most DVs do not create any donor or acceptor states and thus are electronically inactive.

Extrinsic defects (I, Sn, Fe, Ni, Cu, Zn, O) were also investigated as adatoms on a monolayer, as substitutional defects and as intercalated species in a 4 layer slab, giving a comprehensive overview of experimentally reported impurities in BP. Substitutional Sn defects were found to lead to p-doping of the crystal, while Cu adatoms on the surface induce n-type behaviour. Our work provides fundamental insight into the influence of intrinsic and extrinsic point defects on the electronic properties of black phosphorus, which is imperative for future developments of BP technologies. Moreover, our findings of magnetism in BP related to vacancies and TM doping is relevant for the development of future spintronics and solotronics technologies, such as quantum memory devices, gas sensors or quantum computing applications.

## Conflicts of interest

There are no conflicts to declare.

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